

## Tribenzylphosphine oxide

Héctor Novoa de Armas,<sup>a\*</sup> Hiram Pérez,<sup>b</sup> Oswald M. Peeters,<sup>a</sup> Norbert M. Blaton,<sup>a</sup> Camiel J. De Ranter<sup>a</sup> and José Manuel López<sup>b</sup>

<sup>a</sup>Laboratorium voor Analytische Chemie en Medicinale Fysicochemie, Faculteit Farmaceutische Wetenschappen, Katholieke Universiteit Leuven, Van Evenstraat 4, B-3000 Leuven, Belgium, and <sup>b</sup>Inorganic Chemistry Department, Faculty of Chemistry, University of Havana, 10400 Havana, Cuba  
Correspondence e-mail: hector.novoa@farm.kuleuven.ac.be

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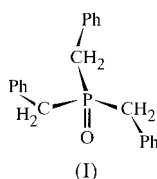
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The title compound, (C<sub>6</sub>H<sub>5</sub>CH<sub>2</sub>)<sub>3</sub>PO, is an organic tertiary phosphine oxide. The molecule has threefold symmetry, with the P—O bond along the threefold axis. Main dimensions include P—O 1.488 (4), P—C 1.823 (3) Å and O—P—C 114.7 (1)°. The crystals were accidentally obtained when preparing complexes of nickel(II) with dibenzylphosphine.

### Comment

The title compound, (I), is an organic phosphorus compound that belongs to a type of tertiary phosphine oxides. In the final stages of the synthesis of dihalogenobis(tribenzylphosphine)-nickel(II) complexes (Pérez *et al.*, 1998), (I) was isolated as colourless needles, possibly formed by an oxidation process due to atmospheric oxygen. The P—O distance agrees with the mean distance of 1.50 Å calculated by Bye *et al.* (1982), based on 62 Ph<sub>3</sub>PO fragments. The P—C and C—C distances are similar to those found in compounds with tribenzylphosphine groups (Kilbourn & Powell, 1975). The two torsion angles P1—C3—C4—C<sub>i</sub> (*i* = 5 and 9) show that the three benzyl groups differ by approximately 180°. The molecules are packed at normal van der Waals distances.



### Experimental

In the recrystallization of dihalogenobis(tribenzylphosphine)-nickel(II) from dichloromethane–butanol (1:1) under an oxygen atmosphere (Pérez *et al.*, 1998), colorless needles of the title compound were obtained.

### Crystal data

C<sub>21</sub>H<sub>21</sub>OP  
*M<sub>r</sub>* = 320.35  
Trigonal, *R*3  
*a* = 16.685 (2) Å  
*c* = 5.468 (1) Å  
*V* = 1318.3 (3) Å<sup>3</sup>  
*Z* = 3  
*D<sub>x</sub>* = 1.211 Mg m<sup>-3</sup>

Mo *K*α radiation  
Cell parameters from 30 reflections  
*θ* = 13.80–27.92°  
*μ* = 0.160 mm<sup>-1</sup>  
*T* = 293 K  
Prism, colourless  
0.56 × 0.32 × 0.20 mm

### Data collection

Stoe Stadi-4 four-circle diffractometer  
*ω* scans  
Absorption correction: *ψ* scan (EMPIR; Stoe & Cie, 1992)  
*T<sub>min</sub>* = 0.913, *T<sub>max</sub>* = 0.969  
5177 measured reflections  
578 independent reflections  
558 reflections with *F*<sup>2</sup> > 2σ(*F*<sup>2</sup>)

*R<sub>int</sub>* = 0.0347  
*θ<sub>max</sub>* = 24.88°  
*h* = -19 → 19  
*k* = -19 → 19  
*l* = 0 → 6  
2 standard reflections  
frequency: 60 min  
intensity decay: none

### Refinement

Refinement on *F*<sup>2</sup>  
*R* [*F*<sup>2</sup> > 2σ(*F*<sup>2</sup>)] = 0.032  
*wR*(*F*<sup>2</sup>) = 0.088  
*S* = 1.068  
578 reflections  
70 parameters  
H-atom parameters constrained

*w* = 1/[σ<sup>2</sup>(*F<sub>o</sub>*<sup>2</sup>) + (0.0568*P*)<sup>2</sup> + 0.3906*P*]  
where *P* = (*F<sub>o</sub>*<sup>2</sup> + 2*F<sub>c</sub>*<sup>2</sup>)/3  
(Δ/σ)<sub>max</sub> = 0.001  
Δ*ρ*<sub>max</sub> = 0.11 e Å<sup>-3</sup>  
Δ*ρ*<sub>min</sub> = -0.12 e Å<sup>-3</sup>  
Absolute structure: Flack (1983)  
Flack parameter = 0.1 (2)

**Table 1**

Selected geometric parameters (Å, °).

P1—O1	1.488 (4)	C4—C3	1.508 (6)
P1—C3	1.823 (3)		
O1—P1—C3	114.7 (1)	C3—C4—C9	120.9 (4)
C3—C4—C5	120.4 (3)	P1—C3—C4	114.3 (2)
O1—P1—C3—C4	65.0 (3)	C9—C4—C3—P1	-86.7 (4)
C5—C4—C3—P1	93.6 (4)		

H atoms were calculated geometrically and included in the refinement, but were restrained to ride on their parent atoms. The isotropic displacement parameters of the H atoms were fixed to 1.3*U*<sub>eq</sub> of their parent atoms.

Data collection: *DIF4* (Stoe & Cie, 1992); cell refinement: *DIF4*; data reduction: *REDU4* (Stoe & Cie, 1992); program(s) used to solve structure: *SIR92* (Altomare *et al.*, 1993); program(s) used to refine structure: *SHELXL97* (Sheldrick, 1997); software used to prepare material for publication: *PARST* (Nardelli, 1983, 1995) and *PARSTCIF* (Nardelli, 1991).

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